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AN 1988-179983 [26] DNN N1988-137431 DNC C1988-080419 TI Bonding wire having high fracture strength - obtd. by hot working alloy ingot of boron and copper, soln. treating, quenching, cold working and ageing. DC L03 M26 (SUMM) SUMITOMO METAL MINING CO PA CYC 1 ΡI JP 6311803<u>3</u> A 19880523 (198826)\* 4p JP 63118033 A JP 1986-263661 19861107 ADT PRAI JP 1986-263661 19861107 JP 63118033 A UPAB: 19930923 Bonding wire comprises by wt. 0.0001-0.02% B, and balance high purity Cu of 99.999% purity, having 25-32 kg/mm2 fracture strength, and 35-41 Vickers hardness of ball hardness. The bonding wire is made by hot working the alloy ingot, soln. treating, followed by quenching; cold working and aging. USE - The bonding wire made by the method, makes the loop wire

USE - The bonding wire made by the method, makes the loop wire conditions pref., as it has high fracture strength, and does not damage semiconductor devices on bonding the wire, as it has low hardness (in Hv) and high ball-neck strength after ball forming. 0/0